Dynasolve™ 2000

Cured Polymer Cleaning Solvent





Dynasolve 2000 is a reactive formulated solvent that is used to remove anhydride-cured epoxy, urethane, and silicone. It is used in both industrial and electronic applications. It is aluminum-safe for a 24-hour period.

CLEANING APPLICATIONS:

Depotting and decapsulating of electronic components

Industrial polymer removal and cleaning

ADVANTAGES:

All-in-one product works on several types of polymers

More efficient than acetone, MEK & other solvents

Formulated to be highly selective

Aluminum safe for 24hr period

High flash point

SPECIFICATIONS:

| Specific gravity: | 1.07 |
|-------------------|---------------|
| Boiling point: | 482°F (250°C) |
| Flash point: | 217°F (103°C) |

MATERIALS REMOVED:

Anhydride-cured epoxy
Urethane
Silicone

PRODUCT USAGE GUIDELINES

(SEE SDS FOR EH&S INFORMATION)

- 1. Heat Dynasolve 2000 and immerse part.
 - Heat to 245°F (118°C) for anhydride cured epoxy
 - Heat to 200°F (93°C) for urethane or silicone
- 3. Observe carefully. If polymer appears unaffected after 1 hour, increase temperature to $250^{\circ} 300^{\circ}F$ ($121^{\circ} 148^{\circ}C$).
- After successful removal of material, rinse with alcohol or water.
- 5. If polymer appears unaffected after 2 hours, call for technical support.

MATERIAL COMPATIBILITY:

| Recommended materials including: | |
|----------------------------------|--------|
| Most metals | |
| Teflon® | |
| Polyethylene & polyprop | ovlene |
| rolyethylene & polyprop | Sylene |
| Avoid materials includ | |
| , , , , , , , , , | |
| Avoid materials includ | |



For more information, please contact us at:

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